

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of : Customer Number: 20277
Minh Van NGO, et al. : Confirmation Number: 3500
Serial No.: 10/617,451 : Group Art Unit: 2812
Filed: July 11, 2003 : Examiner: W. Lindsay, Jr.
For: PECVD SILICON-RICH OXIDE LAYER FOR REDUCED UV CHARGING

RESPONSE TO RESTRICTION REQUIREMENT

Mail Stop Restriction Requirement
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

In the Office Action dated August 9, 2004, the Examiner imposed a Restriction Requirement pursuant to 35 U.S.C. §121, requiring election of either:

Group I. Claims 12 through 19 directed to a semiconductor device; or

Group II. Claims 1 through 11 directed to a method.

In response Applicants elect to prosecute device claims 12 through 19 (Group I).

Favorable consideration of device claims 12 through 19 is solicited.

Applicants also solicit rejoinder of non-elected method claims 1 through 11, upon the determination of an allowable device claim, pursuant to the provisions of MPEP§821.04.

To the extent necessary, a petition for an extension of time under 37 C.F.R. 1.136 is hereby made. Please charge any shortage in fees due in connection with the filing of this paper, including

extension of time fees, to Deposit Account 500417 and please credit any excess fees to such deposit account.

Respectfully submitted,

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Date: August 19, 2004